

**UNITED STATES DEPARTMENT OF COMMERCE****Patent and Trademark Office**Address: COMMISSIONER OF PATENTS AND TRADEMARKS
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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.
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09/072,959 05/05/98 PAN

P 2919.1US

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MM92/0425

 EXAMINER

FOURSON III.G

ART UNIT	PAPER NUMBER
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2823

DATE MAILED: 04/25/00

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

Office Action Summary	Application No. 09/072,759	Applicant(s) Papasouliotis et al
	Examiner George Fourson	Group Art Unit 2823

Responsive to communication(s) filed on the amendment filed 2/14/00.

This action is **FINAL**.

Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11; 453 O.G. 213.

A shortened statutory period for response to this action is set to expire 3 month(s), or thirty days, whichever is longer, from the mailing date of this communication. Failure to respond within the period for response will cause the application to become abandoned. (35 U.S.C. § 133). Extensions of time may be obtained under the provisions of 37 CFR 1.136(a).

Disposition of Claims

Claim(s) 1-5, 11-17, 25-28, and 33-38 is/are pending in the application.

Of the above, claim(s) _____ is/are withdrawn from consideration.

Claim(s) _____ is/are allowed.

Claim(s) 1-5, 11-17, 25-28, and 33-38 is/are rejected.

Claim(s) _____ is/are objected to.

Claims _____ are subject to restriction or election requirement.

Application Papers

See the attached Notice of Draftsperson's Patent Drawing Review, PTO-948.

The drawing(s) filed on _____ is/are objected to by the Examiner.

The proposed drawing correction, filed on _____ is approved disapproved.

The specification is objected to by the Examiner.

The oath or declaration is objected to by the Examiner.

Priority under 35 U.S.C. § 119

Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d).

All Some* None of the CERTIFIED copies of the priority documents have been

received.

received in Application No. (Series Code/Serial Number) _____.

received in this national stage application from the International Bureau (PCT Rule 17.2(a)).

*Certified copies not received: _____.

Acknowledgement is made of a claim for domestic priority under 35 U.S.C. § 119(e).

Attachment(s)

Notice of References Cited, PTO-892

Information Disclosure Statement(s), PTO-1449, Paper No(s). _____

Interview Summary, PTO-413

Notice of Draftsperson's Patent Drawing Review, PTO-948

Notice of Informal Patent Application, PTO-152

--- SEE OFFICE ACTION ON THE FOLLOWING PAGES ---

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The amendments to page 5, line 121 and page 5, line 13, in the amendment filed 5/5/98 could not be performed. The indicated terms to be replaced do not occur in those locations.

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

Claims 1-4,11-14,16,25-27,33-35 and 37 are rejected under 35 U.S.C. 102(e) as being anticipated by Tsai et al.

Tsai et al discloses formation of dielectric layer 32 and buffer layer 34 over semiconductor substrate 30, patterning of layers 32 and 34, trench etching using the patterned layers as a trench mask, thermal oxidation of the trench walls, isotropic etching of layer 34, filling of the trench with silicon dioxide, removal of a portion of the silicon dioxide and removal of the buffer layer 34 (fig.5a-5h).

Claims 5,15,28 and 36 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tsai et al as applied to claims 1-4,11-14,16,25-27,33-35 and 37 above, and further in view of Pan et al.

Tsai et al does not disclose annealing of the trench fill material. Annealing of trench fill material is disclosed by Pan et al. It would have been within the scope of one of ordinary skill in the art to employ the process of Pan et al for its known intended purpose to achieve the trench filling step of Tsai et al

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Claims 17 and 38 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tsai et al as applied to claims 1-4,11-14,16,25-27,33-35 and 37 above, and further in view of the following comments.

Tsai et al discloses recessing layer 34 50-1000Å (col.5, line 36). See MPEP 2144.05.

Any inquiry of a general nature or relating to the status of this application should be directed to the Group Receptionist whose telephone number is (703) 308-0956. **See MPEP 203.08.**

Any inquiry concerning this communication or earlier communications from the examiner should be directed to examiner George Fourson whose telephone number is (703) 308-2544. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (703) 308-4918. The fax number for this group is (703)308-7722(and 7724 and 7382). MPEP 502.01 contains instructions regarding procedures used in submitting responses by facsimile transmission.


George Fourson
Primary Examiner
Art Unit 2823

GFourson
April 24, 2000